Programme: Garment Technology Level: Undergraduate

Course Syllabus

1. Course Name: Practice of CAD Technology in Garment Industry Course Code: PCAP313251

2. Credit Units: 1 (0/1/2) (0 units of theory/ 1 unit of practice/ 2 units of self-study)

Duration: 5 weeks (0 hours of theory + 9 hours of practice, and 18 hours of self-study per week)

3. Course Instructors

1/ MSc. Nguyen Thanh Hau 2/ MSc. Le Quang Lam Thuy 3/ MSc. Mai Quynh Trang 4/ Dr. Nguyen Tuan Anh

4. Course Requirements

Prerequisite courses: Preparation of Garment Manufacturing

Previous courses: CAD/CAM in Garment Industry

Parallel courses: None **5. Course Description**

The module teaches students how to perform operations when using the functions with AccuMark software. At the same time, the module also helps students to identify and select the appropriate functions of the software to design and marker making for a specific product, to meet the needs of real production deployment

6. Course Goals

Goals	Goal Description	ELOs	Scale
G1	Concepts of CAD technology application to support design pattern	ELO-03	4
	and marker making		
G2	Analysing and evaluating the applicability of CAD software	ELO-06	4
	functions in the process of pattern design and marker making	ELO-08	4
G3	Teamwork, communication skills and reading comprehension of		3
	instructional manuals using CAD software in English.		
G4	Functions in CAD software to provide appropriate design process	ELO-15	6
	for each specific style	ELO-16	4

7. Course Learning Outcomes (CLOs)

CLC)s	CLO Description	ELOs	
G1	CLO1	Select suitable applications to set up data when applying		4
	CLOI	Accumark software into the preparation process for product		
		Analyze and test different functions in Pattern Design software	ELO-06	4
		to design details of products and create a professional and	ELO-08	4
G2	CLO2	responsible working style; proactively updating knowledge in		
		the field of careers; demonstrating progressive spirit and		
		confidence in solving problems.		
G3	CLO3	Apply English skills in CAD technology application.	ELO-11	3
		Develop the functions in Accumark software system to select the	ELO-15	6
		appropriate processes when designing pattern and marker and	ELO-16	4
G4	CLO4	adjust the extended settings of each specific functions in		
		Accumark system to optimize the process of deploying the		
		pattern design and marker making for different product styles.		

8. Learning Ethics

Students must do homework by themselves. If plagiarism is found students will get zero point.

9. Course Content

Week	Content	CLOs	Scale
	Exercise 1: Set up the basic data supports pattern design and		
	marker making process (0,9,18)		
	A/ Content and pedagogical methods in class: (9)	CLO1	4
	Content:	CLO2	4
	1. Set up the Storage Area		
	2. Set up the P-Notch		
1	3. Set up the P-User Environment		
1	4. Set up the Rule table		
	Pedagogical methods:		
	+ Presentation of lecture		
	+ Discussion		
	+ Làm mẫu		
	B/ Self-study content: (18)	CLO1	4
	Research methods to design shirts and trousers.		
	Exercise 2: Design of semi- finished pattern for shirt (18,0,36)		
	A/ Content and pedagogical methods in class: (18)	CLO1	4
	Content:	CLO2	4
	Setting the Preference Option	CLO3	3
	1. Design the basic frame	CLOS	
	2. Design the base line		
	3. Design the mark point		
2-3	4. Trace the semi-finished pattern		
2-3	5. Modify the semi - finished pattern		
	Pedagogical methods:		
	+ Presentation of lecture		
	+ Discussion		
	+ Discussion + Làm mẫu		
	B/ Self-study content: (36)	CLO1	1
	Practice the menu Point, Line, and Piece.	CLO1 CLO2	4 4
	Exercise 3: Design of finished pattern for shirt (9,0,18)	CLO2	4
	A/ Content and pedagogical methods in class: (9)	CLO1	4
	Content:	CLO1 CLO2	4
	1. Design intermediate sizes		•
	2. Add/Define seam	CLO3	3
	3. Add/define notch		
4	4. Add/define drill		
	Pedagogical methods:		
	+ Presentation of lecture		
	+ Discussion		
	+ Sampling		
	B/ Self-study content: (18)	CLO1	4
	+ Practice the menu Measure, Grade, Notch	CLO3	4
	Exercise 4: Marker Making (9,0,18)	2200	
	A/ Content and pedagogical methods in class: (9)	CLO1	4
	Content:	CLO4	4
	Digitize samples	CLOT	'
5	1. Set up the Model Editors		
	2. Set up the Lay limit Editors		
	3. Set up the Eay mint Editors		
	4. Set up the Order Editors		
	5. Process Oder		
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6. Finel exam		
Pedagogical methods:		
+ Presentation of lecture		
+ Discussion		
+ Sampling		
B/ Self-study content: (6)	CLO1	4
+ Practice the marker making for trousers, short	CLO4	4

10.Learning Resources

- Textbooks:
- 1. Nguyen Thanh Hau. Textbook of Cad in Apparel. HCMC National University Press, 2017.
 - References:
- 1. Gerber Garment Technology Data Management USA, 2003;
- 2. Gerber Garment Technology Pattern Design USA, 2003;
- 3. Gerber Garment Technology Marker Making USA, 2003.

11.Student Assessment

- Grading scale: **10** - Assessment plan:

Type	Content	Timeline	Assessment method	CLOs	Rate (%)
Formative Assigments				50	
Ex#1	Set up the basic data supports pattern design and marker making process	Week 1	Exercise	CLO3	10
Ex#2	Design semi- finished pattern for shirt	Week 3	Exercise	CLO3 CLO4	25
Ex#3	Design finished pattern for shirt	Week 4	Exercise	CLO4	10
Ex#4	Marker making for shirt	Week 5	Exercise	CLO4	5
	Summative Assigments				50
	Complete design of 1 piece according to technical documents		Exercise	CLO1 CLO2 CLO3 CLO4	50
Total				100	

12.Date of first approval: August 1st, 201	Date of first	approval:	August	1st,	2012
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Dean Head of Department Compiler

Vu Minh Hanh, M.Ed

Nguyen Ngoc Chau, PhD

Nguyen Thanh Hau, M.Ed

Instructor:

14. Date and Up-to-date content

1st time: Date: August 25th, 2015
- Update content and structure of the programme adjusted

- Update content and structure of the programme adjusted in: teaching content and assessment method

Nguyen Ngoc Chau, PhD